

SLOVENSKI STANDARD
oSIST prEN ISO 22765:2019
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Tehnologija jedrskih goriv - Sintrani peleti (U,Pu)O₂ - Navodilo za pripravo keramografske preiskave mikrostrukture (ISO 22765:2016)

Nuclear fuel technology - Sintered (U,Pu)O₂ pellets - Guidance for ceramographic preparation for microstructure examination (ISO 22765:2016)

Kernbrennstofftechnologie - Gesinterte (U,Pu)O₂-Pellets - Leitfaden für die keramographische Herstellung der Proben zur Untersuchung des Feingefüges (ISO 22765:2016)

Technologie du combustible nucléaire - Pastilles (U,Pu)O₂ frittées - Préconisations relatives à la préparation céramographique pour examen de la microstructure (ISO 22765:2016)

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27.120.30	Cepljivi materiali in jedrska gorivna tehnologija	Fissile materials and nuclear fuel technology
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Nuclear fuel technology — Sintered (U,Pu)O₂ pellets — Guidance for ceramographic preparation for microstructure examination

*Technologie du combustible nucléaire — Pastilles (U,Pu)O₂ frittées
— Préconisations relatives à la préparation céramographique pour
examen de la microstructure*

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Contents

Page

Foreword	iv
1 Scope	1
2 Normative references	1
3 Terms and definitions	1
4 Principle	1
5 Description	2
6 Equipment	2
7 Reagents and resin	2
8 Operating procedure	3
8.1 Specimen cutting.....	3
8.2 Resin embedding.....	3
8.3 Rough polishing.....	3
8.4 Final polishing.....	3
9 Structure development	4
9.1 General.....	4
9.2 Development by thermal treatment.....	4
9.3 Development by chemical etching.....	4
9.4 Development by ion etching.....	5
Bibliography	7

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ISO 22765:2016(E)

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The committee responsible for this document is ISO/TC 85, *Nuclear energy, nuclear technologies, and radiological protection*, Subcommittee SC 5, *Nuclear installations, processes and technologies*.

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